

7. (Amended) The corrosion-resistive member set forth in claim 1, which has a thermal conductivity of  $50 \text{ W/m} \cdot \text{K}$  or less.

8. (Amended) The corrosion-resistive member set forth in claim 1, wherein the corrosive gas is a halogen-based corrosive gas or a plasma of the halogen-based corrosive gas.

9. (Amended) A semiconductor-producing article comprising the corrosion-resistive member set forth in claim 1 as a substrate.

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